

ABSTRACT

The present invention relates to a cyclohexyl ring-containing polyether compound which has, in a molecule, two or more polymerizable unsaturated groups typified by (meth)acryloyloxy groups and one or more acid groups typified by carboxyl groups. The polyether compound provides: a resin composition which has high developability with a dilute alkali and sensitivity and is suitable for use in image formation, e.g., for forming a solder resist or pigment-dispersed resist for a printed circuit board, etc.; and a cured article obtained by curing the resin composition.